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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/698,556	11/03/2003	Kaoru Okitaka	00862.023292.	1114
5514 7590 03/07/2008 FITZPATRICK CELLA HARPER & SCINTO 30 ROCKEFELLER PLAZA NEW YORK, NY 10112				
EXAMINER				
KIM, EUNHEE				
ART UNIT		PAPER NUMBER		
2123				
MAIL DATE		DELIVERY MODE		
03/07/2008		PAPER		

Please find below and/or attached an Office communication concerning this application or proceeding.

The time period for reply, if any, is set in the attached communication.

Office Action Summary

Application No.

10/698,556

Applicant(s)

OKITAKA, KAORU

Examiner

Eunhee Kim

Art Unit

2123

-- The MAILING DATE of this communication appears on the cover sheet with the correspondence address --
Period for Reply

A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) OR THIRTY (30) DAYS, WHICHEVER IS LONGER, FROM THE MAILING DATE OF THIS COMMUNICATION.

- Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication.
- If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication.
- Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).

Status

- 1) ☒ Responsive to communication(s) filed on 11/27/2007.
- 2a) ☐ This action is **FINAL**. 2b) ☒ This action is non-final.
- 3) ☐ Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under *Ex parte Quayle*, 1935 C.D. 11, 453 O.G. 213.

Disposition of Claims

- 4) ☒ Claim(s) 1 is/are pending in the application.
- 4a) Of the above claim(s) _____ is/are withdrawn from consideration.
- 5) ☐ Claim(s) _____ is/are allowed.
- 6) ☒ Claim(s) 1 is/are rejected.
- 7) ☐ Claim(s) _____ is/are objected to.
- 8) ☐ Claim(s) _____ are subject to restriction and/or election requirement.

Application Papers

- 9) ☐ The specification is objected to by the Examiner.
- 10) ☐ The drawing(s) filed on _____ is/are: a) ☐ accepted or b) ☐ objected to by the Examiner.
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).
Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).
- 11) ☐ The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.

Priority under 35 U.S.C. § 119

- 12) ☒ Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).
- a) ☒ All b) ☐ Some * c) ☐ None of:
1. ☒ Certified copies of the priority documents have been received.
 2. ☐ Certified copies of the priority documents have been received in Application No. _____.
 3. ☐ Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).

* See the attached detailed Office action for a list of the certified copies not received.

Attachment(s)

- 1) ☐ Notice of References Cited (PTO-892)
- 2) ☐ Notice of Draftsperson's Patent Drawing Review (PTO-948)
- 3) ☐ Information Disclosure Statement(s) (PTO/55/08)
Paper No(s)/Mail Date _____
- 4) ☐ Interview Summary (PTO-413)
Paper No(s)/Mail Date _____
- 5) ☐ Notice of Informal Patent Application
- 6) ☐ Other: _____

DETAILED ACTION

1. Applicant is informed that the examiner of record has been changed.
2. A request for continued examination under 37 CFR 1.114, including the fee set forth in 37 CFR 1.17(e), was filed in this application after final rejection. Since this application is eligible for continued examination under 37 CFR 1.114, and the fee set forth in 37 CFR 1.17(e) has been timely paid, the finality of the previous Office action has been withdrawn pursuant to 37 CFR 1.114. Applicant's submission filed on 11/27/2007 has been entered.
3. Claims 1 is presented for examination.

Claim Rejections - 35 USC § 103

4. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negated by the manner in which the invention was made.

5. Claim 1 is rejected under 35 U.S.C. 103(a) as being unpatentable over Fan et al. (US 6,704, 693) in view of Yu et al. (US 6,096,088).

Fan et al. teaches a geometric model conversion method of converting a three-dimensional CAD geometric analytical model of a thin-walled structure into a two-dimensional analytical model (Col. 2 lines 12-67), comprising;

a step of generating a plurality of tetrahedral solid elements each of which has single-layered structure in a plate thickness direction, by dividing an input three-dimensional CAD geometric analytical model which has a thin-walled structure (Col. 2 lines 12-67, Figures 2 and 3b and the description),

a step of connecting intermediate nodes of sides that extend in a direction of plate thickness in each tetrahedral solid element to generate a plurality of triangular shell elements or rectangular shell elements as the two-dimensional analytical model (Fig. 9-11 and the description), and

a step of executing an injection molding analysis with respect to each shell element of the two-dimensional analytical model generated in said connecting step and outputting results of the injection molding analysis (Abstract, Col. 1 lines 15-22).

Fan et al. does not explicitly teaches a single layered structure in the plate thickness direction.

Yu et al. teaches a single layered structure in the plate thickness direction (Figure 7B).

Fen et al. and Yu et al. are analogous art because they are both related to a structural analysis.

Therefore, it would have been obvious to one of ordinary skill in the art of at the time the invention was made to include a single layered structure of Yu et al., with the method for the structural analysis of component of Fan et al. because using a single layered structure is a well-known process to a skilled artisan in a method of structural analysis of component. Yu et al.

teaches an improved system that ensures fidelity and reduces the computation time on the model (Col. 1 lines 30-55)

Response to Arguments

6. Applicant's arguments filed 11/27/2007 have been fully considered but they are not persuasive.

Applicants have argued that:

It is acknowledged that Fan discloses use of a tetrahedral solid element, and a triangular shell element, per se. These teachings, however, are directed to two different, conventional methods of structural analysis--solid element and shell element, each having their own advantages and disadvantages (see column 2, lines 41-52). Because of the disadvantages associated with both conventional methods, Fan uses a structural analysis method that generates a shell element model of pentahedral elements. Applicant's unique method of generating a plurality of tetrahedral solid elements and connecting intermediate nodes of sides that extend in a direction of plate thickness in each tetrahedral solid element to generate a plurality of triangular shell elements or rectangular shell elements as the two dimensional analytical model is not taught or suggested by Fan.

The examiner disagrees since Fan et al. teaches solid elements that are simple geometric solid such as tetrahedra (Col. 1 lines 44-45), not pentahedral. Furthermore, the office takes position that Fan et al. teaches the step of intermediate nodes of sides that extend in a direction of plate thickness in each tetrahedral solid element to generate a plurality of triangular shell elements or rectangular shell elements as the two-dimensional analytical model in Fig. 9-11(also see the description).

Conclusion

7. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Eunhee Kim whose telephone number is 571-272-2164. The examiner can normally be reached on 8:30am-5:00pm Monday to Friday.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Paul Rodriguez can be reached on 571-272-3753. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see <http://pair-direct.uspto.gov>. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

Eunhee Kim
GAU 2123
2/28/2008

/Paul L Rodriguez/
Supervisory Patent Examiner,
Art Unit 2123